

# Carrier Transport

## pn-junctions



# Review

n-type

$$N_D > N_A \quad n = N_D - N_A$$

$$p = \frac{n_i^2}{n} = \frac{n_i^2}{N_D - N_A}$$

$$n = N_c \exp\left(\frac{E_F - E_c}{k_B T}\right) = N_D - N_A$$



$$E_F = E_c - k_B T \ln\left(\frac{N_c}{N_D - N_A}\right)$$

p-type

$$N_A > N_D \quad p = N_A - N_D$$

$$n = \frac{n_i^2}{p} = \frac{n_i^2}{N_A - N_D}$$

$$p = N_v \exp\left(\frac{E_v - E_F}{k_B T}\right) = N_A - N_D$$



$$E_F = E_v + k_B T \ln\left(\frac{N_v}{N_A - N_D}\right)$$

# Drift

		$E_g$ (eV)	$\mu_n$ (cm <sup>2</sup> /V-s)	$\mu_p$ (cm <sup>2</sup> /V-s)	$m_n^*/m_o$ ( $m_l, m_h$ )	$m_p^*/m_o$ ( $m_{lh}, m_{hh}$ )	$a$ (Å)	$\epsilon_r$	Density (g/cm <sup>3</sup> )	Melting point (°C)
Si	(i/D)	1.11	1350	480	0.98, 0.19	0.16, 0.49	5.43	11.8	2.33	1415
Ge	(i/D)	0.67	3900	1900	1.64, 0.082	0.04, 0.28	5.65	16	5.32	936
SiC ( $\alpha$ )	(i/W)	2.86	500	—	0.6	1.0	3.08	10.2	3.21	2830
AlP	(i/Z)	2.45	80	—	—	0.2, 0.63	5.46	9.8	2.40	2000
AlAs	(i/Z)	2.16	1200	420	2.0	0.15, 0.76	5.66	10.9	3.60	1740
AlSb	(i/Z)	1.6	200	300	0.12	0.98	6.14	11	4.26	1080
GaP	(i/Z)	2.26	300	150	1.12, 0.22	0.14, 0.79	5.45	11.1	4.13	1467
GaAs	(d/Z)	1.43	8500	400	0.067	0.074, 0.50	5.65	13.2	5.31	1238
GaN	(d/Z, W)	3.4	380	—	0.19	0.60	4.5	12.2	6.1	2530
GaSb	(d/Z)	0.7	5000	1000	0.042	0.06, 0.23	6.09	15.7	5.61	712
InP	(d/Z)	1.35	4000	100	0.077	0.089, 0.85	5.87	12.4	4.79	1070
InAs	(d/Z)	0.36	22600	200	0.023	0.025, 0.41	6.06	14.6	5.67	943
InSb	(d/Z)	0.18	10 <sup>5</sup>	1700	0.014	0.015, 0.40	6.48	17.7	5.78	525
ZnS	(d/Z, W)	3.6	180	10	0.28	—	5.409	8.9	4.09	1650*
ZnSe	(d/Z)	2.7	600	28	0.14	0.60	5.671	9.2	5.65	1100*
ZnTe	(d/Z)	2.25	530	100	0.18	0.65	6.101	10.4	5.51	1238*
CdS	(d/W, Z)	2.42	250	15	0.21	0.80	4.137	8.9	4.82	1475
CdSe	(d/W)	1.73	800	—	0.13	0.45	4.30	10.2	5.81	1258
CdTe	(d/Z)	1.58	1050	100	0.10	0.37	6.482	10.2	6.20	1098
PbS	(i/H)	0.37	575	200	0.22	0.29	5.936	17.0	7.6	1119
PbSe	(i/H)	0.27	1500	1500	—	—	6.147	23.6	8.73	1081
PbTe	(i/H)	0.29	6000	4000	0.17	0.20	6.452	30	8.16	925

$$\vec{v}_{d,n} = -\mu_n \vec{E} \quad \vec{v}_{d,p} = \mu_p \vec{E}$$

$$\vec{j} = -ne\vec{v}_{d,n} + pe\vec{v}_{d,p} = (ne\mu_n + pe\mu_p) \vec{E} = \sigma \vec{E}$$

# Matthiessen's rule

---

$$e\vec{E} = m^* \frac{d\vec{v}}{dt}$$

$$\frac{1}{\tau_{sc}} = \frac{1}{\tau_{sc,lattice}} + \frac{1}{\tau_{sc,impurity}}$$

phonons, temperature dependent

mostly temperature independent

$$\frac{1}{\mu} = \frac{1}{\mu_{lattice}} + \frac{1}{\mu_{impurity}}$$

$$\sigma = \frac{1}{\rho} = ne\mu_n + pe\mu_p$$

doping increases the conductivity by increasing the carrier density but decreases the mobility

# Mobility calculator

$$\mu = \mu_{min} + \frac{\mu_{max} - \mu_{min}}{1 + (N/N_{ref})^\gamma}$$

For Electrons:

$$\mu_{min} = 47 \left( \frac{T}{300} \right)^{-1.23} \frac{\text{cm}^2}{\text{Vs}}$$

$$\Delta\mu = \mu_{max} - \mu_{min} = 1373 \left( \frac{T}{300} \right)^{-2.38} \frac{\text{cm}^2}{\text{Vs}}$$

$$N_{ref} = 1,05 \cdot 10^{17} \left( \frac{T}{300} \right)^{3.65} \text{ cm}^{-3}; \gamma = 0,68 \left( \frac{T}{300} \right)^{-0.32}$$

For Holes:

$$\mu_{min} = 36 \left( \frac{T}{300} \right)^{-0.87} \frac{\text{cm}^2}{\text{Vs}}$$

$$\Delta\mu = \mu_{max} - \mu_{min} = 438 \left( \frac{T}{300} \right)^{-2.01} \frac{\text{cm}^2}{\text{Vs}}$$

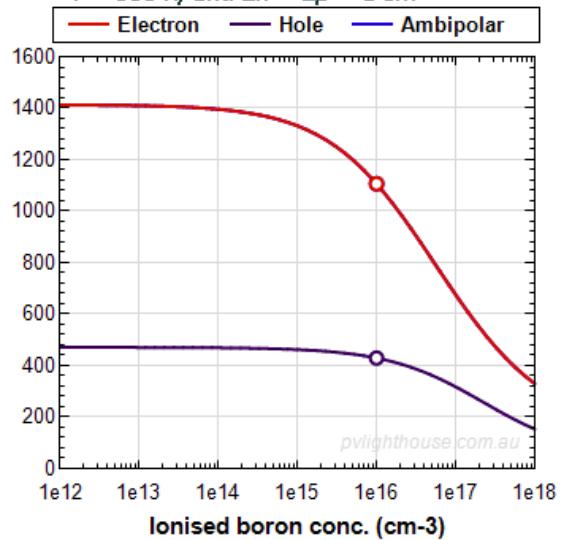
$$N_{ref} = 2,85 \cdot 10^{17} \left( \frac{T}{300} \right)^{2.93} \text{ cm}^{-3}; \gamma = 0,65 \left( \frac{T}{300} \right)^{0.26}$$

INPUTS		
Semiconductor material	c-silicon	Excess electron conc. $\Delta n$
Dopant atom	boron	Excess hole conc. $\Delta p$
Ionised dopant conc.	$1E+16$ cm <sup>-3</sup>	Electron eff. lifetime $\tau_{eff,e}$
Temperature T	300 K	Hole eff. lifetime $\tau_{eff,h}$

Carrier concentrations			Carrier mobility etc.		
Equilibrium $n_0, p_0$ (cm <sup>-3</sup> )	Excess $\Delta n, \Delta p$ (cm <sup>-3</sup> )	Net $n, p$ (cm <sup>-3</sup> )	Mobility $\mu_e, \mu_h, \mu_a$ (cm <sup>2</sup> V <sup>-1</sup> s <sup>-1</sup> )	Diffusivity $D_e, D_h, D_a$ (cm <sup>2</sup> s <sup>-1</sup> )	Diff Length $L_e, L_h, L_a$ (cm)
ions	9300	1.0	9300	1107	28.61
	$1.0E+16$	1.0	$1.0E+16$	429.3	11.10
olar				1107	28.61
					5.349E-2
					3.331E-2

Resistivity ( $\Omega\text{-cm}$ )	
rium	$\rho_0$ 1.454
i-state	$\rho$ 1.454

Mobility vs ionised dopant concentration  
for boron-doped c-silicon with  
 $T = 300 \text{ K}$ , and  $\Delta n = \Delta p = 1 \text{ cm}^{-3}$



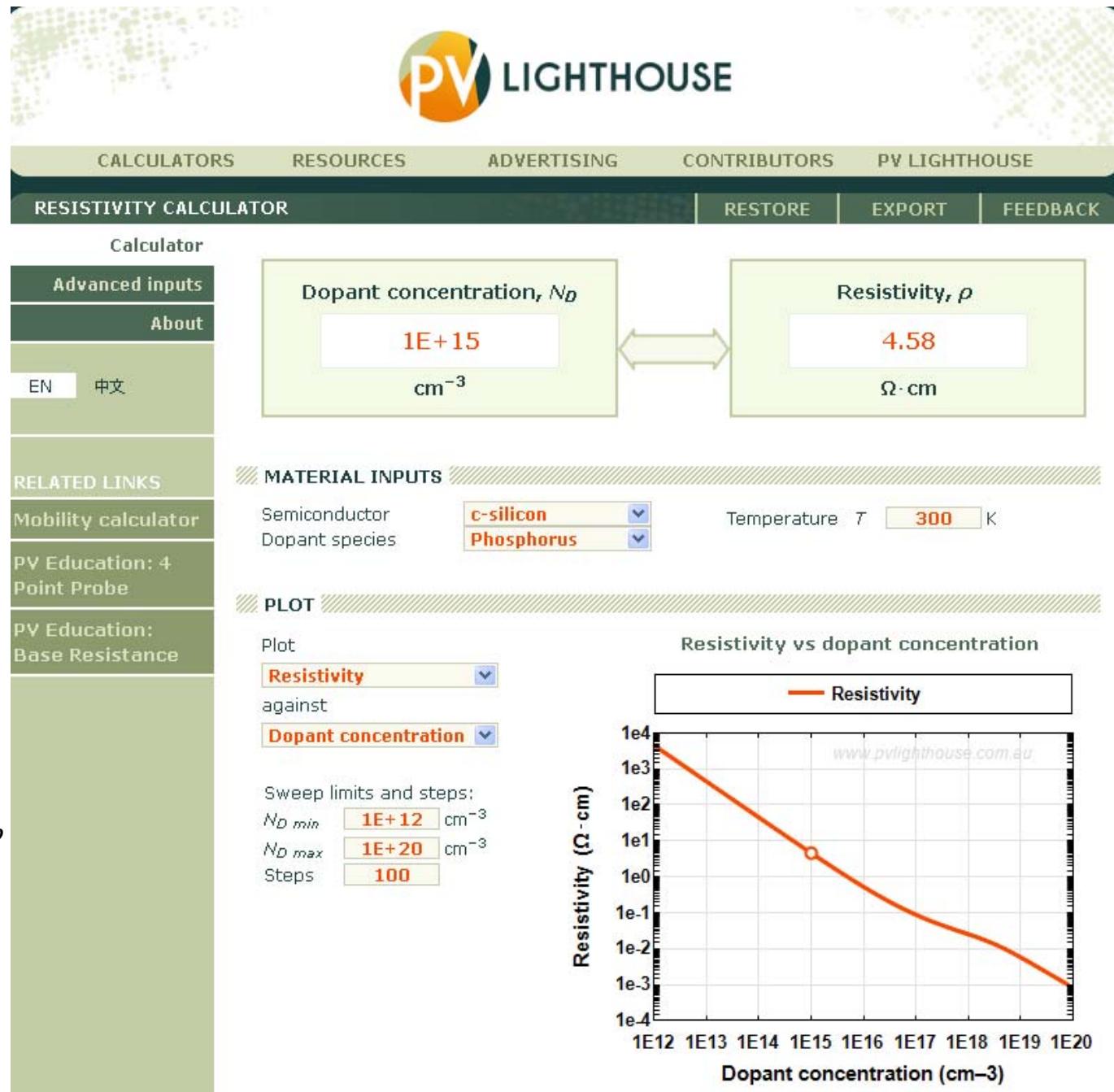
ture inputs		
Mobility	$1E+12$ cm <sup>-3</sup>	
Ionised dopant conc.	$1E+18$ cm <sup>-3</sup>	
points	50	

# Resistivity calculator

$$n = N_c \exp\left(\frac{E_F - E_c}{k_B T}\right)$$

$$p = N_v \exp\left(\frac{E_v - E_F}{k_B T}\right)$$

$$\sigma = \frac{1}{\rho} = ne\mu_n + pe\mu_p$$



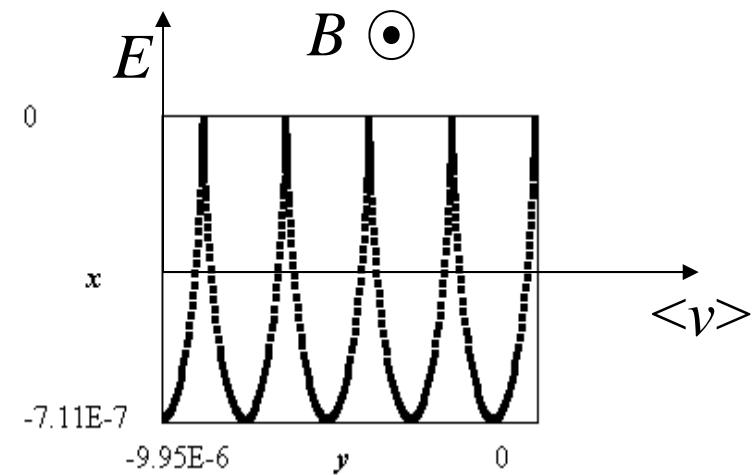
<http://www.pvlighthouse.com.au/calculators/Resistivity%20calculator/Resistivity%20calculator.aspx>

# Crossed $E$ and $B$ fields

---

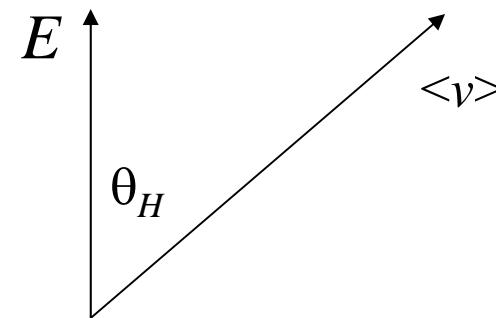
Ballistic transport

$$\vec{F} = m\vec{a} = -e(\vec{E} + \vec{v} \times \vec{B})$$



Diffusive transport

Hall angle:



$$\theta_H = \tan^{-1} \left( -\frac{eB_z \tau_{sc}}{m^*} \right)$$

# Magnetic field (diffusive transport)

---

$$\vec{F} = m\vec{a} = -e\vec{E} = e \frac{\vec{v}_d}{\mu}$$

$$\vec{F} = m\vec{a} = -e(\vec{E} + \vec{v}_d \times \vec{B}) = e \frac{\vec{v}_d}{\mu}$$

If  $B$  is in the  $z$ -direction, the three components of the force are

$$-\mu(E_x + v_{dy}B_z) = v_{dx}$$

$$-\mu(E_y - v_{dx}B_z) = v_{dy}$$

$$-\mu E_z = v_{dz}$$

# Magnetic field

---

$$v_{d,x} = -\mu E_x - \mu B_z v_{d,y}$$

$$v_{d,y} = -\mu E_y + \mu B_z v_{d,x}$$

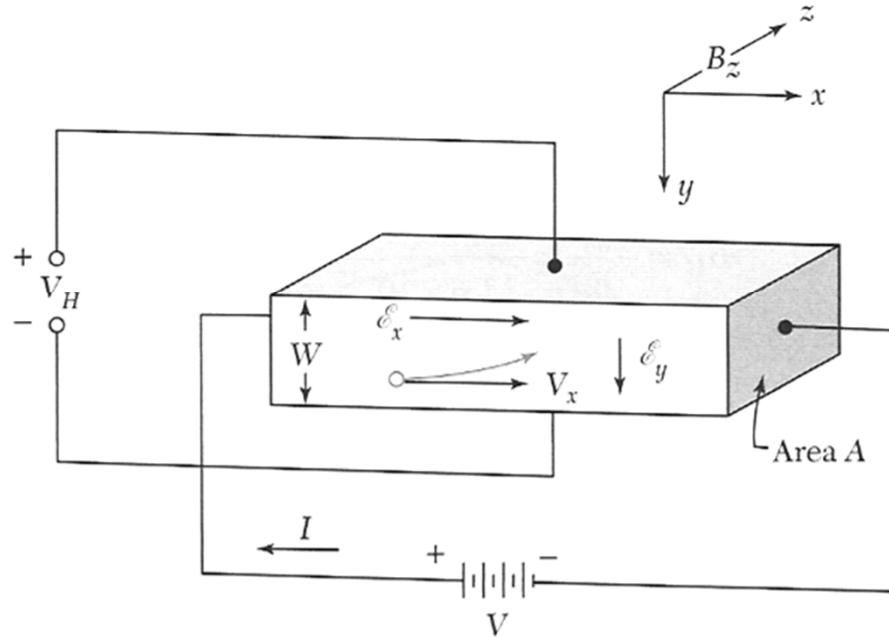
$$v_{d,z} = -\mu E_z$$

If  $E_y = 0$ ,

$$v_{d,y} = -\mu B_z v_{d,x}$$

$$\tan \theta_H = -\mu B_z$$

# The Hall Effect (diffusive regime)



$$v_{d,x} = -\mu E_x - \mu B_z v_{d,y}$$

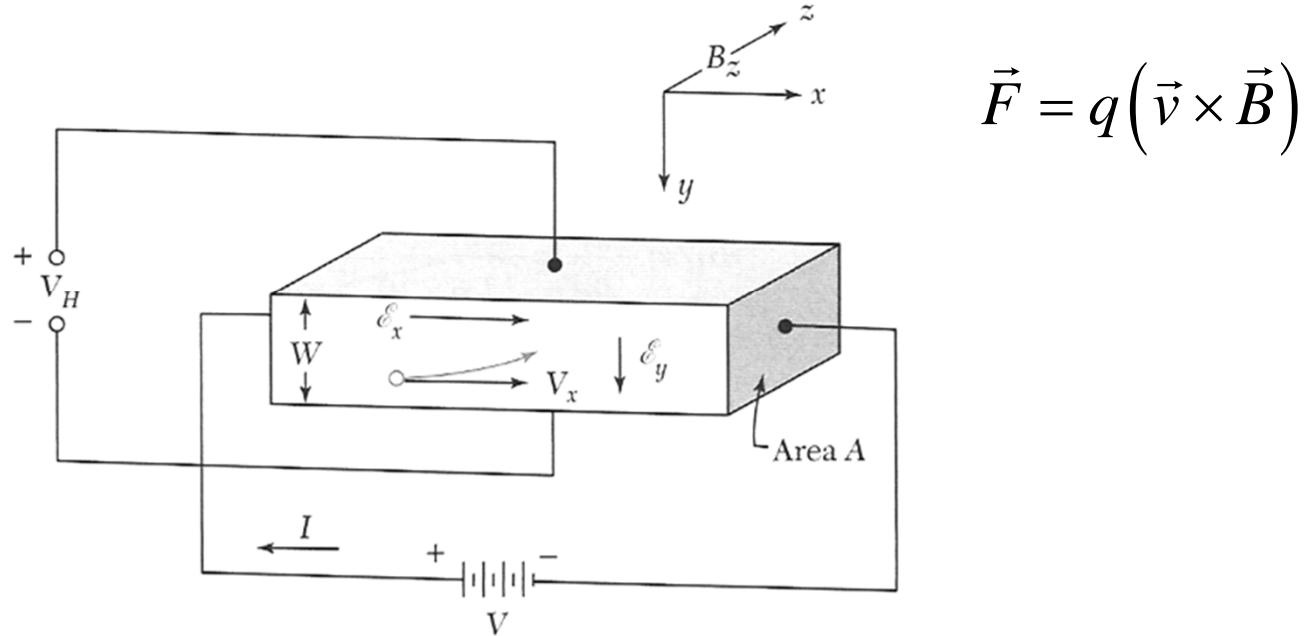
$$v_{d,y} = -\mu E_y + \mu B_z v_{d,x}$$

$$v_{d,z} = -\mu E_z$$

If  $v_{d,y} = 0$ ,

$$E_y = v_x B_z = V_H/W = R_H j_x B_z \quad V_H = \text{Hall voltage}, R_H = \text{Hall Constant}$$

# The Hall Effect (diffusive regime)



$$\vec{F} = q(\vec{v} \times \vec{B})$$

$$E_y = v_x B_z = V_H/W = R_H j_x B_z$$

$V_H$  = Hall voltage,  $R_H$  = Hall Constant

$$j_x = I/A$$

$$v_x = -j_x/ne \quad \text{for n-type}$$

$$v_x = j_x/pe \quad \text{for p-type}$$

$$R_H = -1/ne \quad \text{for n-type}$$

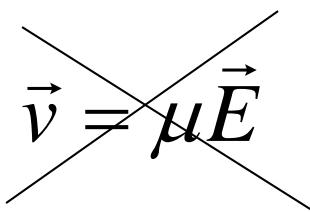
$$R_H = 1/pe \quad \text{for p-type}$$

# Ballistic transport in transistors

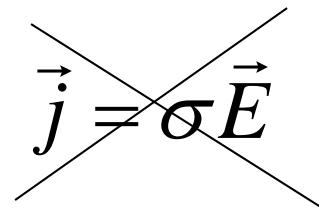
---

The mean free path  $\sim 100$  nm > gate length  $\sim 20$  nm

$v$  not proportional to  $E$

$$\vec{v} = \mu \vec{E}$$


$j$  not proportional to  $E$

$$\vec{j} = \sigma \vec{E}$$


nonlocal response

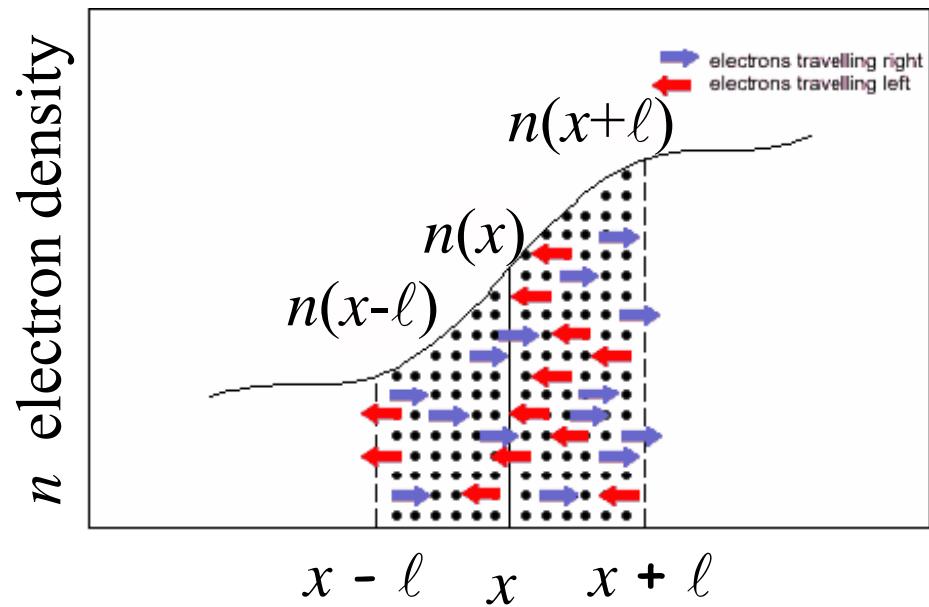
Electrons bend in a magnetic field like they do in vacuum.

# Diffusion

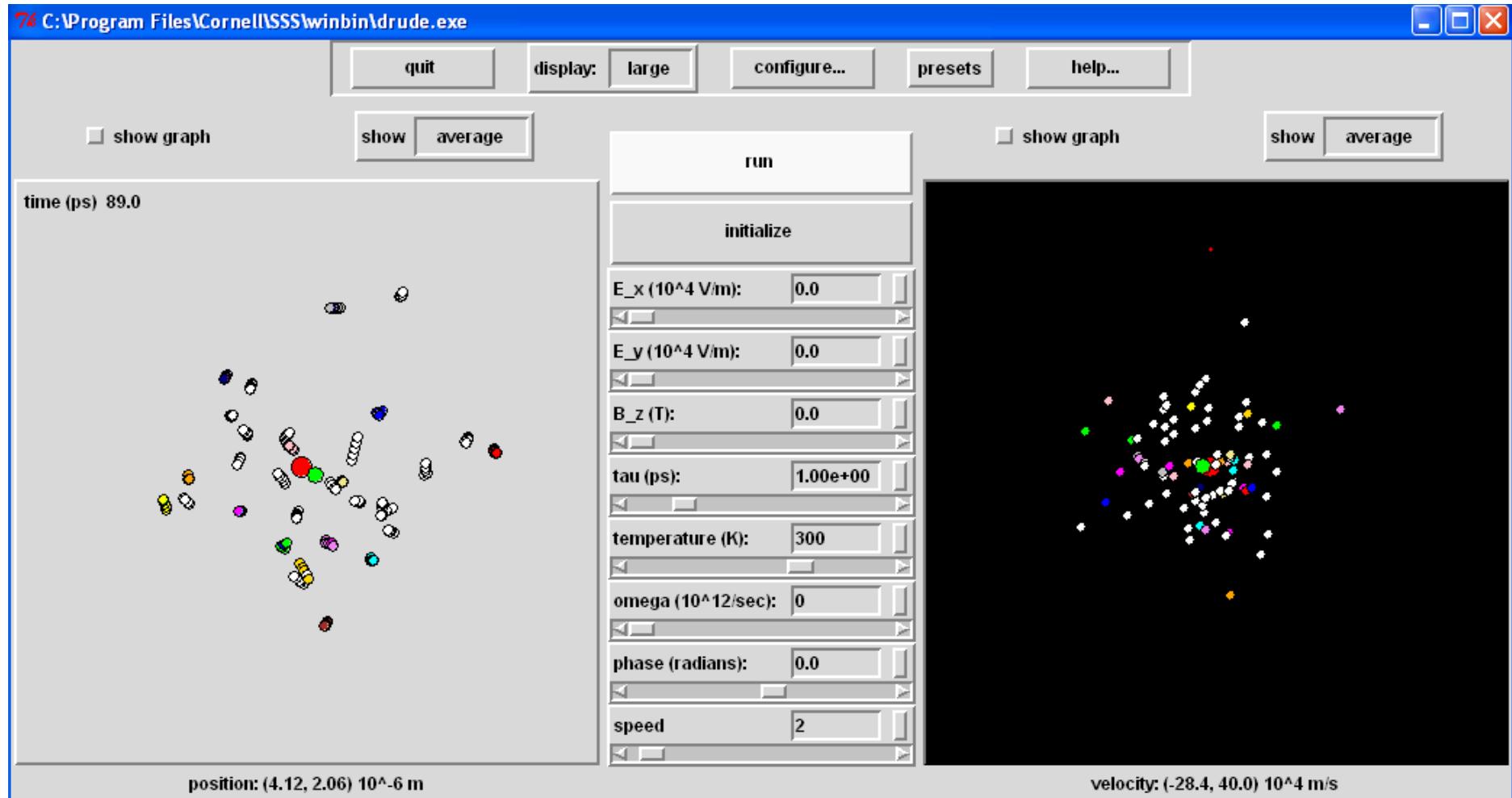
---

$$j_{n,diff} = |e| D_n \frac{dn}{dx}$$

$$j_{p,diff} = -|e| D_p \frac{dp}{dx}$$



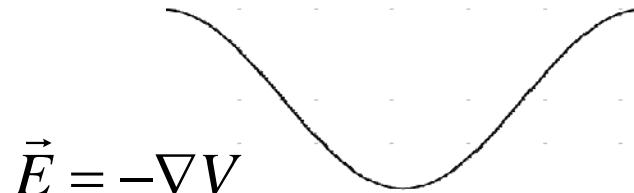
Diffusion is from high concentration to low concentration.



If no forces are applied, the electrons diffuse.  
The average velocity moves against an electric field.  
In just a magnetic field, the average velocity is zero.  
In an electric and magnetic field, the electrons move in a straight line at  
the Hall angle.

# Einstein relation

---



$$n(x) = A \exp\left(\frac{-eV(x)}{k_B T}\right) \text{ Boltzmann factor}$$

In equilibrium, drift = diffusion

$$-en\mu\vec{E} + eD\nabla n = 0$$

$$\nabla n = -\frac{e}{k_B T} A \exp\left(\frac{-eV_{pot}}{k_B T}\right) \nabla V = -\frac{ne}{k_B T} \nabla V = \frac{ne\vec{E}}{k_B T}$$

$$-en\mu\vec{E} + eD \frac{ne\vec{E}}{k_B T} = 0$$

$$D = \frac{\mu k_B T}{e}$$

Über die von der molekularkinetischen Theorie der Wärme geforderte Bewegung von in ruhenden Flüssigkeiten suspendierten Teilchen

# Current Density Equations

---

Drift  
↓

$$\vec{j}_n = -ne\mu_n \vec{E} + eD_n \nabla n$$

Diffusion  
↗

$$\vec{j}_p = pe\mu_p \vec{E} - eD_p \nabla p$$

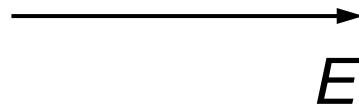
$$\vec{j}_{total} = \vec{j}_n + \vec{j}_p$$

# Current Density Equations

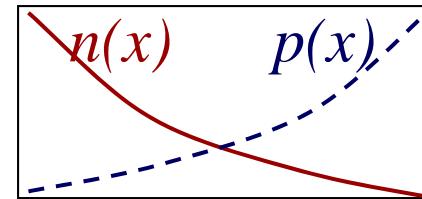
note: electron and hole currents have same direction

electric current = charge  $\times$  particle flow

**drift**



**diffusion**



$$\xleftarrow{-n\mu_e E} \textcircled{-}$$

*current*

$$j_e = -e \times \text{flow}$$

$$\textcircled{-} \xrightarrow{\text{flow}}$$

*current*

$$-D_n(dn/dx)$$

$\textcircled{+}$

*current*

$$j_p = e \times \text{flow}$$

$$\xrightarrow{p\mu_p E} \textcircled{+}$$

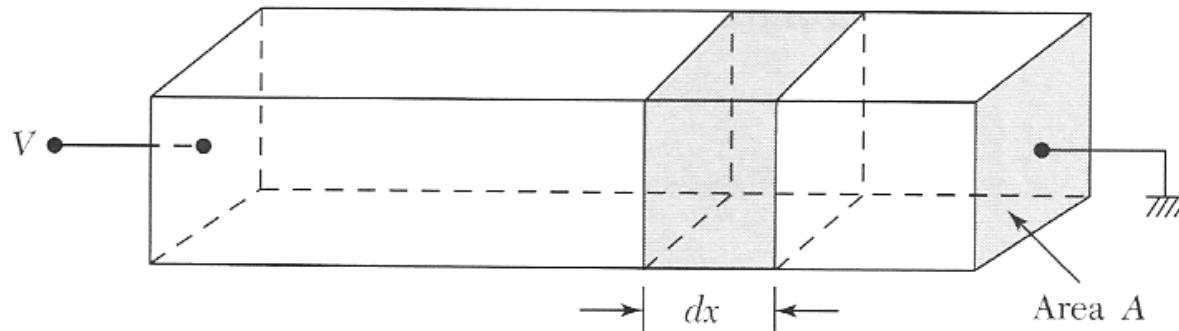
*current*

$$\textcircled{+} \xleftarrow{D_p(dp/dx)}$$

*current*

# Continuity equations

---



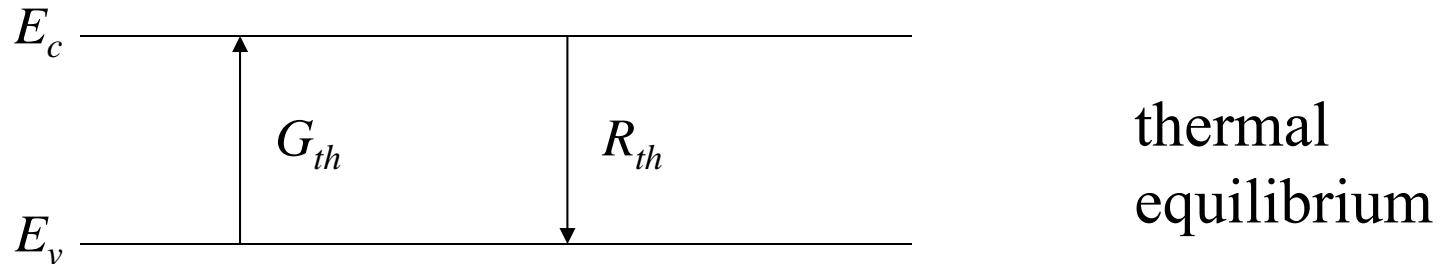
$$\frac{\partial n}{\partial t} = \frac{1}{e} \nabla \cdot \vec{j}_n + G_n - R_n$$

$$\frac{\partial p}{\partial t} = -\frac{1}{e} \nabla \cdot \vec{j}_p + G_p - R_p$$

$j_n$  and  $j_p$  consist of drift and diffusion terms

# Generation and Recombination

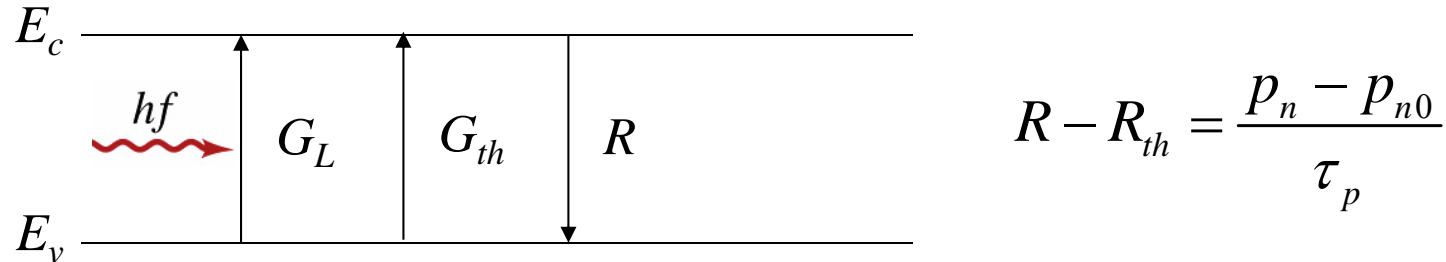
---



Shining light on a semiconductor or injecting electrons or holes from a contact can result in a **non-equilibrium** distribution  $np \neq n_i^2$



# Recombination

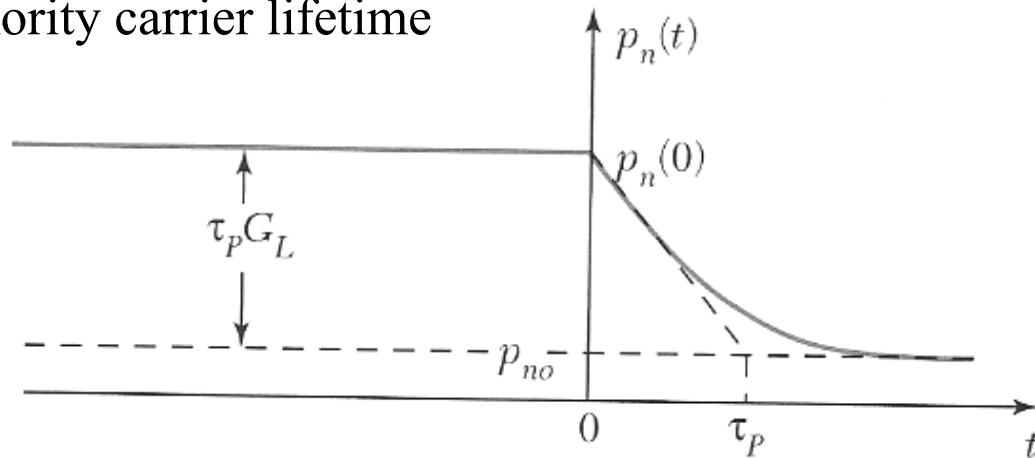


Recombination rate is limit by the density of minority carriers.  
The majority carriers have to find a minority carrier to recombine.

$p_n$  (or  $n_p$ ) = minority carrier concentration

$p_{n0}$  (or  $n_{p0}$ ) = equilibrium minority carrier concentration

$\tau_p$  = minority carrier lifetime



# minority carrier lifetimes

---

p-type

$$n_p(t) = n_{excess} \exp(-t / \tau_n) + n_{p0}$$

n-type

$$p_n(t) = p_{excess} \exp(-t / \tau_p) + p_{n0}$$

minority carrier  
lifetimes

$$np = n_i^2$$

# Continuity equations

$$\frac{\partial n}{\partial t} = \frac{1}{e} \nabla \cdot \vec{j}_n + G_n - R_n$$

---

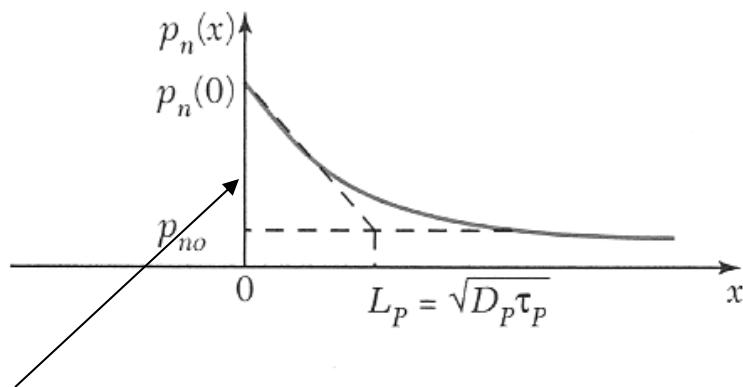
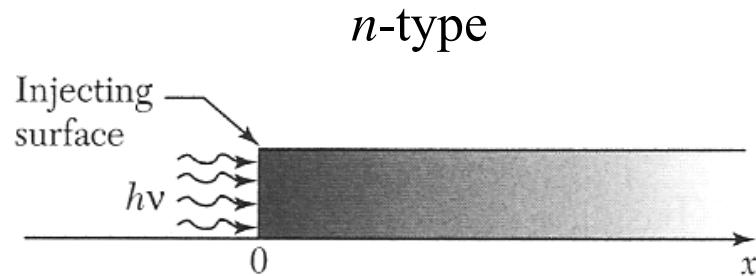
drift:  $\vec{j}_n = -ne\mu_n \vec{E}$   $\nabla \cdot \vec{j}_n = -en\mu_n \nabla \cdot \vec{E} - e\nabla n \mu_n \vec{E}$

diffusion:  $\vec{j}_{n,diff} = |e| D_n \nabla n$   $\nabla \cdot \vec{j}_{n,diff} = |e| D_n \nabla^2 n$

$$\frac{\partial n}{\partial t} = n\mu_n \nabla \cdot \vec{E} + \nabla n \mu_n \vec{E} + D_n \nabla^2 n + G_n - \frac{n - n_0}{\tau_n}$$

$$\frac{\partial p}{\partial t} = -p\mu_p \nabla \cdot \vec{E} - \nabla p \mu_p \vec{E} + D_p \nabla^2 p + G_p - \frac{p - p_0}{\tau_p}$$

# Diffusion Length



Steady state

$$\frac{\partial p_n}{\partial t} = 0 = D_p \frac{\partial^2 p_n}{\partial x^2} - \frac{p_n - p_{n0}}{\tau_p}$$

$$p_n(x) = p_{n0} + (p_n(0) - p_{n0}) \exp\left(\frac{-x}{L_p}\right)$$

Generation only occurs at the surface. There the minority carrier density is  $p_n(0)$ .

# Diffusion Length

---

$$0 = D_p \frac{\partial^2 p_n}{\partial x^2} - \frac{p_n - p_{n0}}{\tau_p} \quad \Leftrightarrow \quad p_n(x) = p_{n0} + (p_n(0) - p_{n0}) \exp\left(\frac{-x}{L_p}\right)$$

$$0 = \frac{D_p (p_n(0) - p_{n0})}{L_p^2} \exp\left(\frac{-x}{L_p}\right) - \frac{(p_n(0) - p_{n0})}{\tau_p} \exp\left(\frac{-x}{L_p}\right)$$

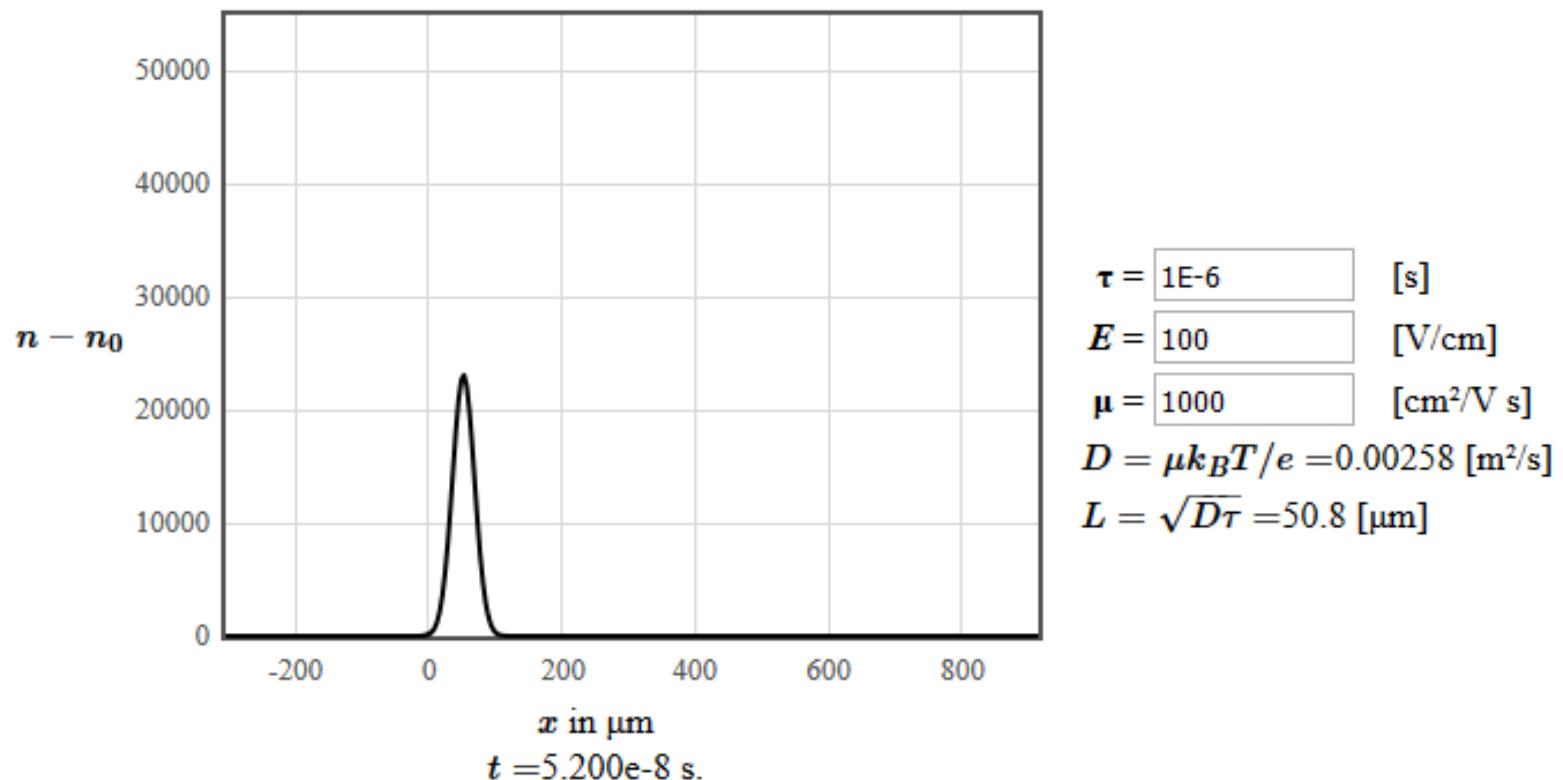
$$L_p = \sqrt{D_p \tau_p}$$

diffusion length,  
typically microns

# Haynes Shockley experiment

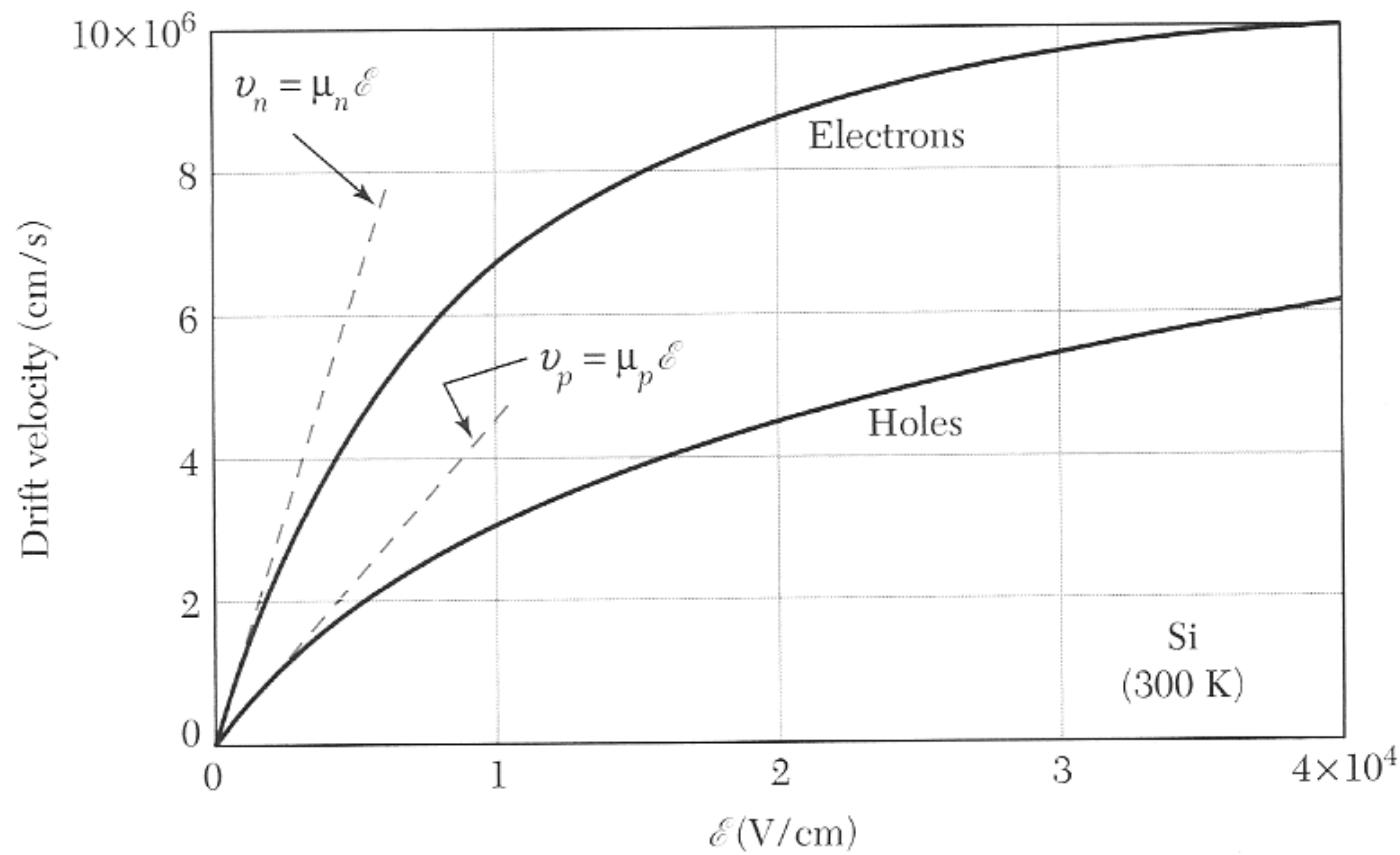
---

$$n_p(x, t) = \frac{n_{generated}}{\sqrt{4\pi D_n t}} \exp\left(-\frac{(x - \mu_n E t)^2}{4D_n t}\right) \exp\left(-\frac{t}{\tau_n}\right) + n_{p0}$$



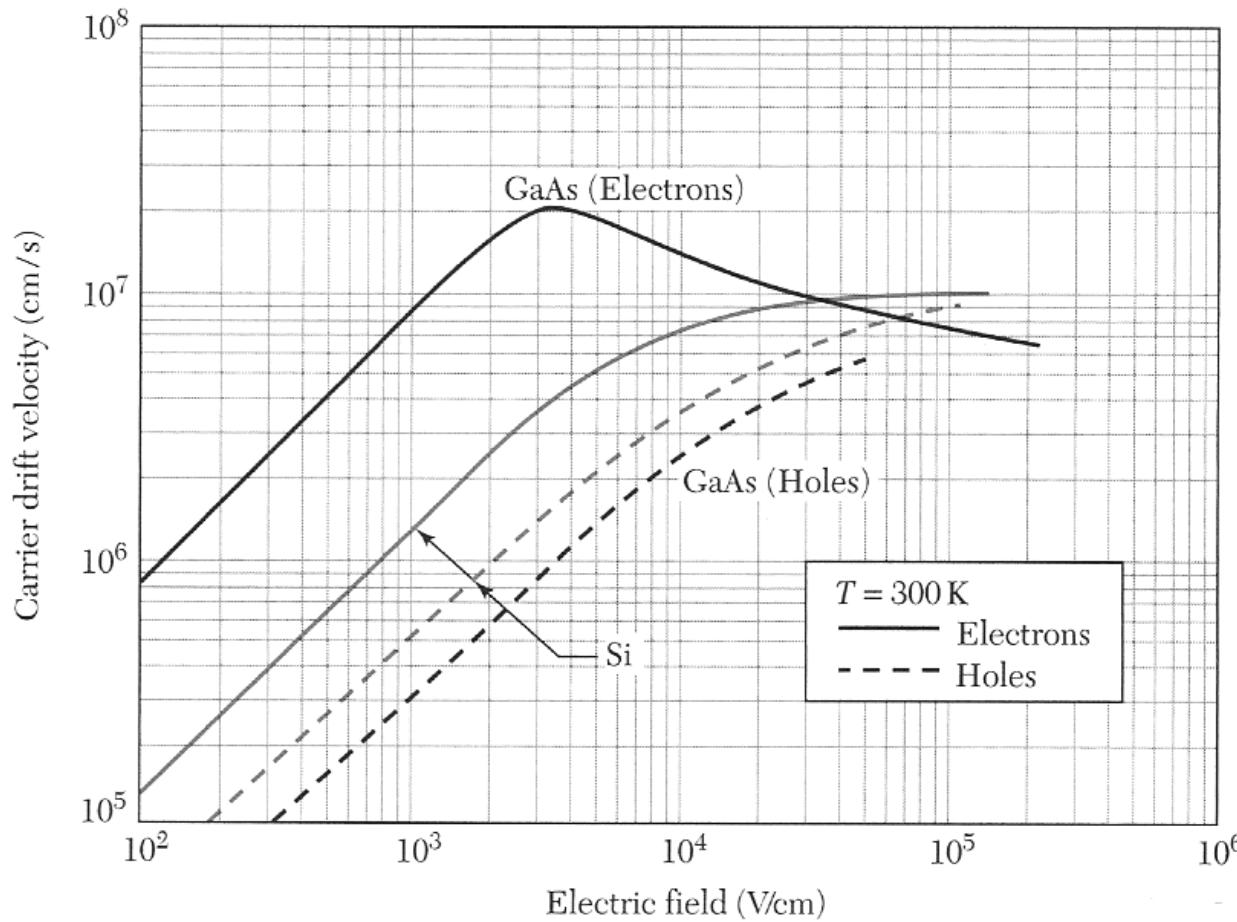
# High Fields

---

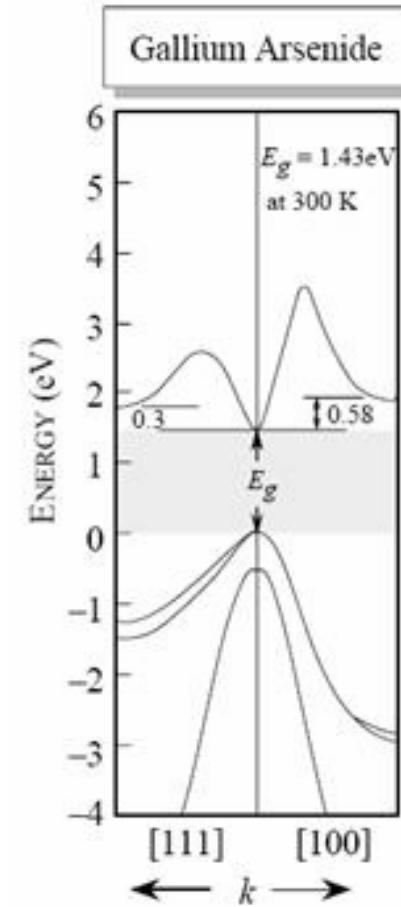


Silicon

# High Fields



GaAs



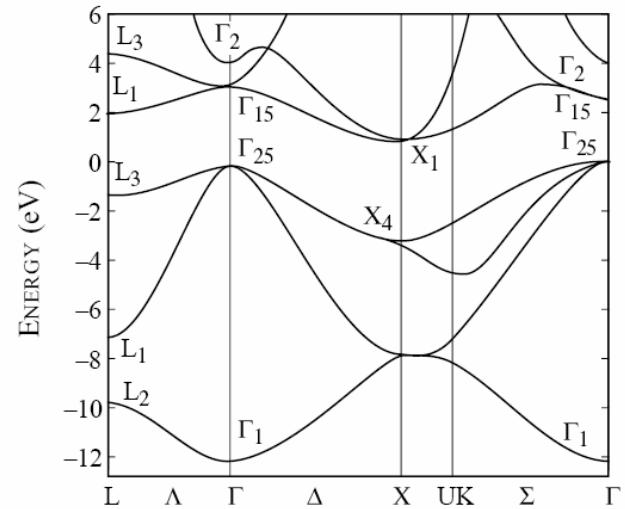
# Impact ionization

---

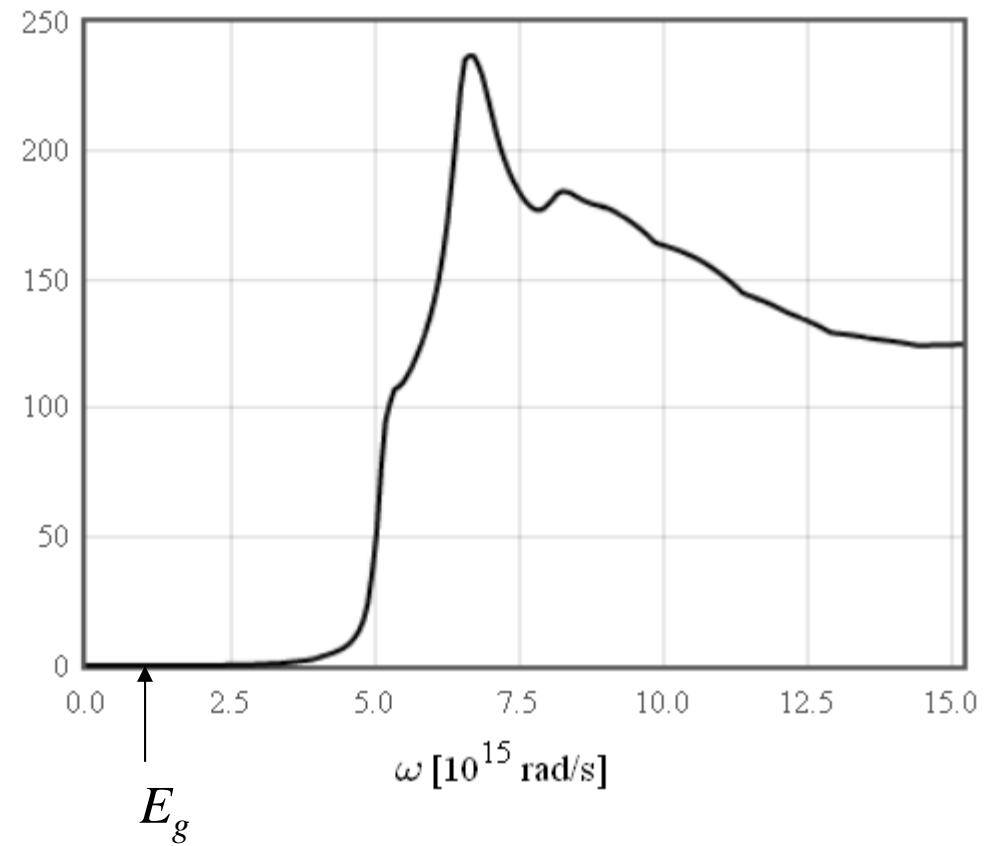
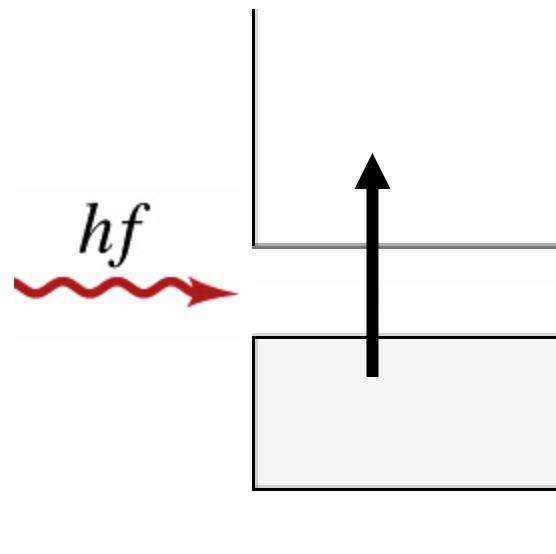
Carriers are accelerated to an energy above the gap before they scatter. They generate more electron-hole pairs. This results in an avalanche breakdown of the device.

# Absorption

$$I = I_0 \exp(-\alpha x)$$

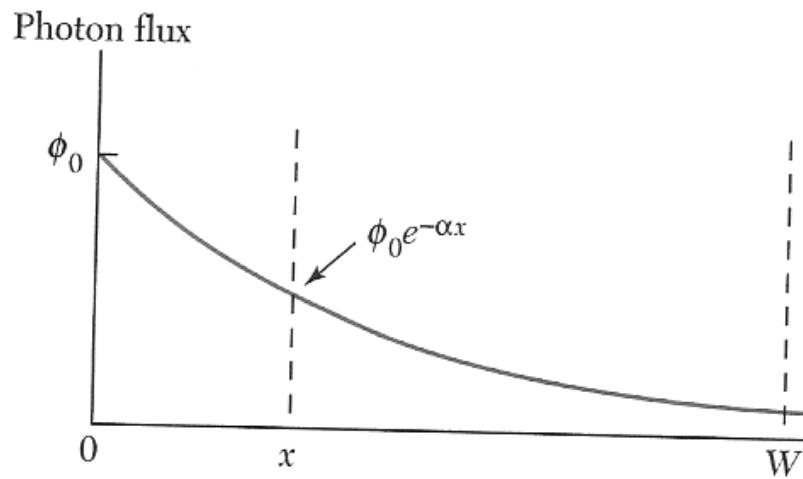


absorption coefficient  $\alpha$



# Absorption

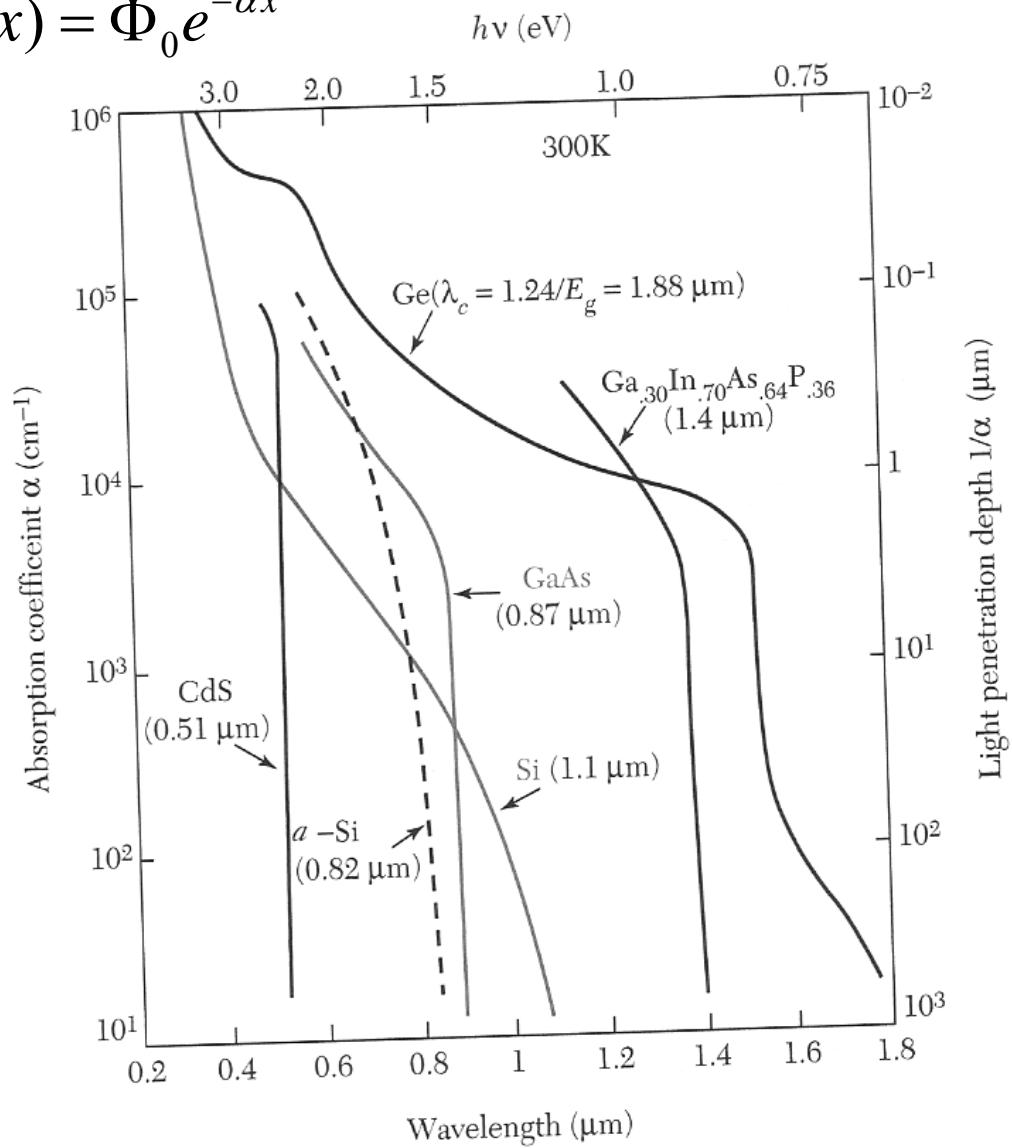
Photon flux:  $\Phi(x) = \Phi_0 e^{-\alpha x}$



Sharp absorption edge for direct bandgap materials

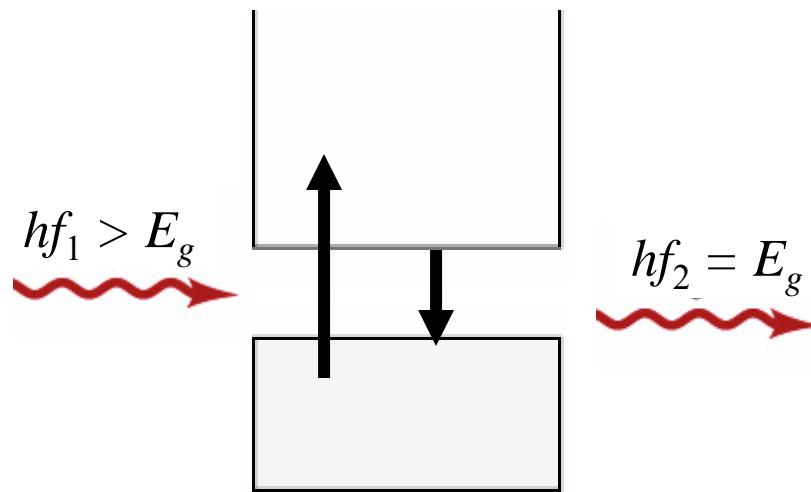
$$\alpha \approx 3.5 \times 10^6 \left( \frac{m_r^*}{m_0} \right)^{3/2} \frac{\sqrt{\hbar\omega - E_g}}{\hbar\omega} \text{ cm}^{-1}$$

direct bandgap



# Photoluminescence

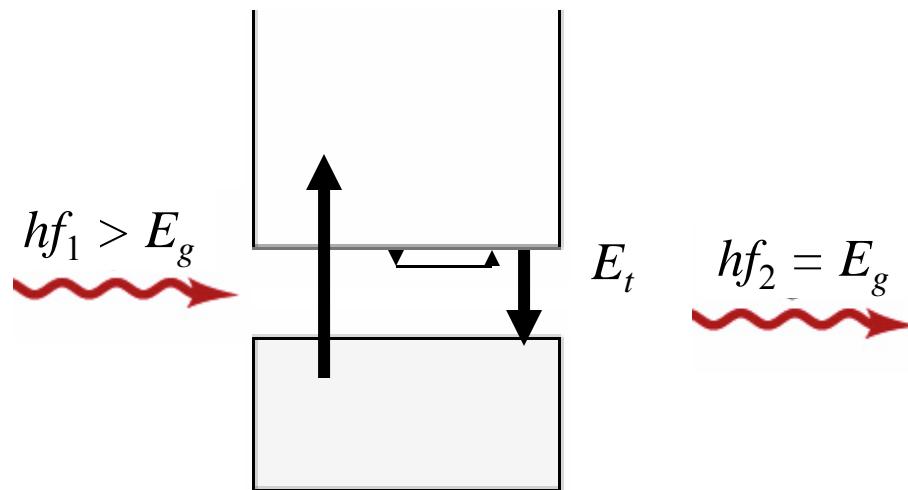
---



In a direct bandgap semiconductor, emission stops  $\sim 10^{-8}$  s after excitation stops.

# Phosphorescence

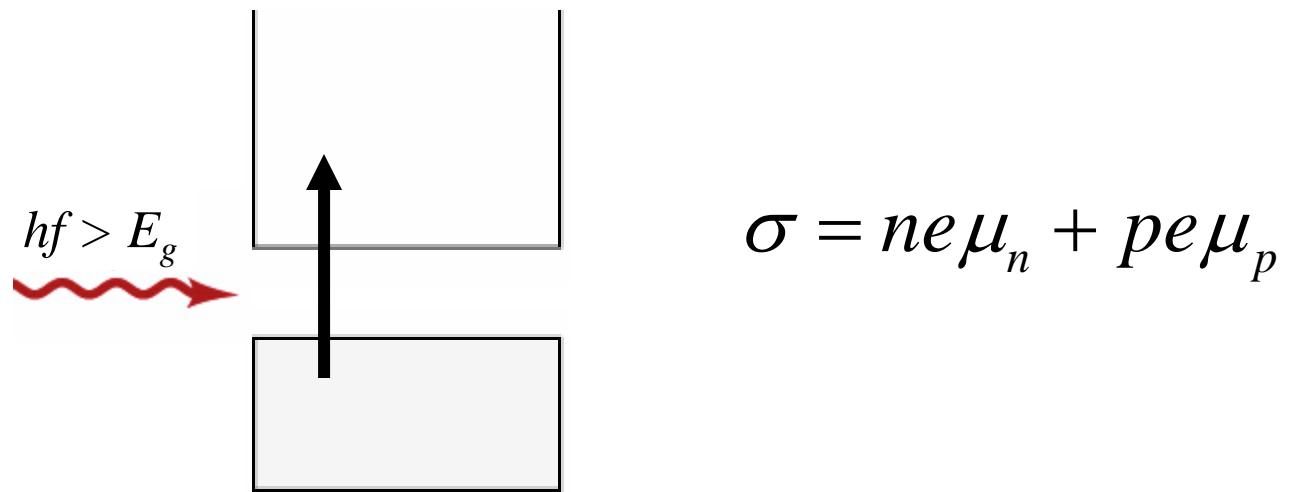
---



An electron falls into a trap and must be thermally excited out before it recombines and emits light.

# Photoconductivity

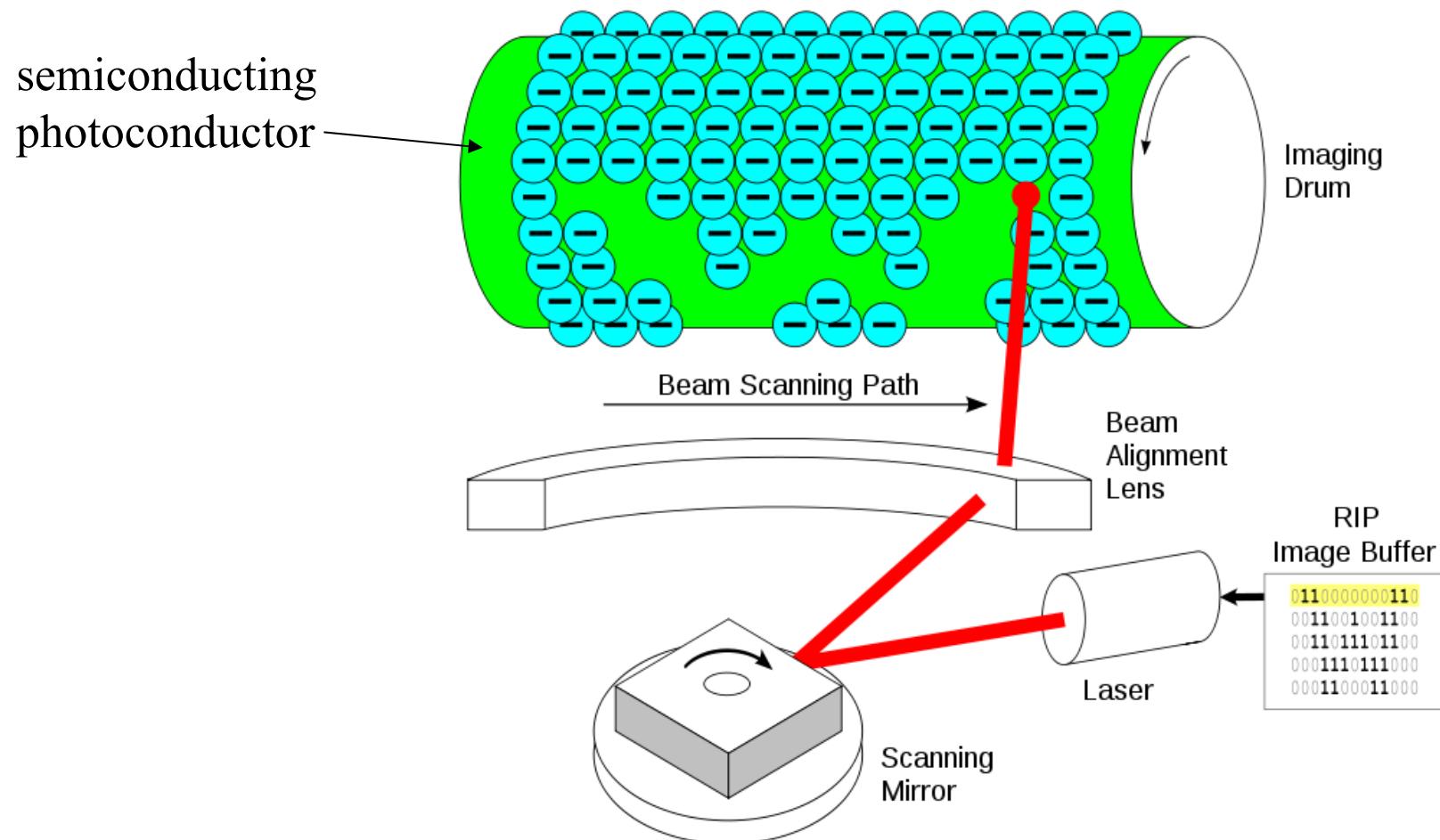
---



Light increases the conductivity of a semiconductor.

# Laser printer

---



# pn junctions

pn junctions are found in:

- diodes
- solar cells
- LEDs
- isolation
- JFETs
- bipolar transistors
- MOSFETs
- solid state lasers

